



Appl. No. 09/360,292

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No.09/360,292
Filing Date July 22, 1999
Inventor Sujit Sharan et al.
Assignee Micron Technology, Inc.
Group Art Unit 1765
Examiner Ahmed, Shamim
Attorney's Docket No.MI22-1106
Title: Plasma Etching Process

RESPONSE TO SEPTEMBER 14, 2005 FINAL OFFICE ACTION
TO ACCOMPANY RCE FILING

To: Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
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AMENDMENTS

Introductory Comments

In response to the Final Office Action dated September 14, 2005, applicant amends and remarks as follows.